

| | |
|-----------------------------|---|
| Title | Carrier dynamics near a crack in GaN microwires with AlGaN multiple quantum wells |
| Authors | Finot, Sylvain;Grenier, Vincent;Zubialevich, Vitaly Z.;Bougerol, Catherine;Pampili, Pietro;Eymery, Joël;Parbrook, Peter J.;Durand, Christophe;Jacopin, Gwéno   |
| Publication date | 2020-12-03 |
| Original Citation | Finot, S., Grenier, V., Zubialevich, V., Bougerol, C., Pampili, P., Eymery, J., Parbrook, P. J., Durand, C. and Jacopin, G. (2020) 'Carrier dynamics near a crack in GaN microwires with AlGaN multiple quantum wells', Applied Physics Letters, 117(22), 221105 (5pp). doi: 10.1063/5.0023545 |
| Type of publication | Article (peer-reviewed) |
| Link to publisher's version | 10.1063/5.0023545 |
| Rights |    2020, the Authors. Published under license by AIP Publishing. This article may be downloaded for personal use only. Any other use requires prior permission of the author(s) and AIP Publishing. This article appeared as: Finot, S., Grenier, V., Zubialevich, V., Bougerol, C., Pampili, P., Eymery, J., Parbrook, P. J., Durand, C. and Jacopin, G. (2020) 'Carrier dynamics near a crack in GaN microwires with AlGaN multiple quantum wells', Applied Physics Letters, 117(22), 221105 (5pp), doi: 10.1063/5.0023545, and may be found at https://doi.org/10.1063/5.0023545 |
| Download date | 2025-01-22 08:37:23 |
| Item downloaded from | https://hdl.handle.net/10468/10828 |



UCC

University College Cork, Ireland
Coláiste na hOllscoile Corcaigh

Carrier dynamics near a crack in GaN microwires with AlGaIn multiple quantum wells

Cite as: Appl. Phys. Lett. **117**, 221105 (2020); <https://doi.org/10.1063/5.0023545>

Submitted: 30 July 2020 . Accepted: 14 November 2020 . Published Online: 03 December 2020

 Sylvain Finot,  Vincent Grenier,  Vitaly Zubialevich,  Catherine Bougerol,  Pietro Pampili,  Joël Eymery,  Peter J. Parbrook,  Christophe Durand, and  Gwénoél Jacopin

COLLECTIONS

Paper published as part of the special topic on [Ultrawide Bandgap Semiconductors UBS2021](#)



View Online



Export Citation



CrossMark

ARTICLES YOU MAY BE INTERESTED IN

[Electrical properties of \(11-22\) Si:AlGaIn layers at high Al contents grown by metal-organic vapor phase epitaxy](#)

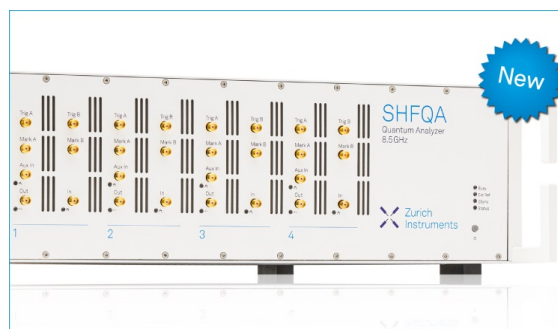
Applied Physics Letters **117**, 221101 (2020); <https://doi.org/10.1063/5.0031468>

[Thermionic emission or tunneling? The universal transition electric field for ideal Schottky reverse leakage current: A case study in \$\beta\$ -Ga₂O₃](#)

Applied Physics Letters **117**, 222104 (2020); <https://doi.org/10.1063/5.0029348>

[Temperature dependence of Ga₂O₃ growth by halide vapor phase epitaxy on sapphire and \$\beta\$ -Ga₂O₃ substrates](#)

Applied Physics Letters **117**, 222101 (2020); <https://doi.org/10.1063/5.0031267>



Your Qubits. Measured.

Meet the next generation of quantum analyzers

- Readout for up to 64 qubits
- Operation at up to 8.5 GHz, mixer-calibration-free
- Signal optimization with minimal latency

Find out more



Carrier dynamics near a crack in GaN microwires with AlGaIn multiple quantum wells

Cite as: Appl. Phys. Lett. **117**, 221105 (2020); doi: [10.1063/5.0023545](https://doi.org/10.1063/5.0023545)

Submitted: 30 July 2020 · Accepted: 14 November 2020 ·

Published Online: 3 December 2020



View Online



Export Citation



CrossMark

Sylvain Finot,^{1,a)} Vincent Grenier,² Vitaly Zubialevich,³ Catherine Bougerol,¹ Pietro Pampili,³ Joël Eymery,⁴ Peter J. Parbrook,³ Christophe Durand,² and Gwénoél Jacopin¹

AFFILIATIONS

¹University Grenoble Alpes, CNRS, Grenoble INP*, Institut Néel, 38000 Grenoble, France

²University Grenoble Alpes, CEA, IRIG, PHELIQS, NPSC, 38000 Grenoble, France

³Tyndall National Institute, University College Cork, Cork T12 R5CP, Ireland

⁴University Grenoble Alpes, CEA, IRIG, MEM, NRS, 38000 Grenoble, France

Note: This paper is part of the Special Topic on Ultrawide Bandgap Semiconductors.

^{a)} Author to whom correspondence should be addressed: sylvain.finot@neel.cnrs.fr

ABSTRACT

Relaxation of tensile strain in AlGaIn heterostructures grown on a GaN template can lead to the formation of cracks. These extended defects locally degrade the crystal quality, resulting in a local increase in non-radiative recombinations. The effect of such cracks on the optical and structural properties of core-shell AlGaIn/AlGaIn multiple quantum wells grown on GaN microwires is comprehensively characterized by means of spectrally and time-correlated cathodoluminescence (CL). We observe that the CL blueshifts near a crack. By performing 6×6 k.p simulations in combination with transmission electron microscopy analysis, we ascribe this shift to the strain relaxation by the free surface near cracks. By simultaneously recording the variations of both the CL lifetime and the CL intensity across the crack, we directly assess the carrier dynamics around the defect at $T = 5$ K. We observe that the CL lifetime is reduced typically from 500 ps to less than 300 ps and the CL intensity increases by about 40% near the crack. The effect of the crack on the optical properties is, therefore, of two natures. First, the presence of this defect locally increases non-radiative recombinations, while at the same time, it locally improves the extraction efficiency. These findings emphasize the need for time-resolved experiments to avoid experimental artifacts related to local changes of light collection.

Published under license by AIP Publishing. <https://doi.org/10.1063/5.0023545>

Efficient ultra-violet (UV) light sources are used in many applications related to spectroscopy, photopolymer curing, water purification, medical treatment, and disinfection. Compared to traditional UV lamps, III-nitride UV light emitting diodes (LEDs) present a number of advantages such as compactness, long lifetime, and being Hg-free.¹ However, despite significant research effort in the past two decades, the external quantum efficiency (EQE) remains rather low (below 20% in the UV-C range²). The factors limiting their EQE are manifold: influence of extended and point defects,³ poor p-doping efficiency,⁴ and modest light extraction.⁵

To overcome some of the inherent limitations of planar *c*-plane LED architectures, the use of nanowire-based UV LEDs has recently emerged.⁶ They already offer some key advantages: higher Mg solubility leading to a more efficient p-doping in the deep-UV^{7,8} and a drastic reduction of extended defects.⁹ A particularly promising approach is based on *m*-plane core-shell wires.^{10–15} In this geometry, the absence of the quantum confined Stark effect and the increased emitting area

contribute to the mitigation of the detrimental effects that appear at high carrier densities. Furthermore, core-shell wires have already been used to develop flexible LEDs,¹⁶ and this configuration could then lead to flexible UV LEDs.

In a core-shell microwire, the emitting dipole is usually coupled to a guided mode where the wire itself acts as a waveguide.¹⁷ As a consequence, for UV emitters, the light extraction could be severely altered due to the detrimental GaN core parasitic absorption. To circumvent this issue, one approach is to use an AlN inner core.¹⁰ However, with such a design, the electrical injection is challenging. Hence, to combine electrical injection and low absorption losses, a solution is to grow an AlGaIn cladding shell to protect the guided mode from inner core absorption losses. To be efficient in the deep UV emission, this cladding layer has to be both Al-rich and thick enough. Under these conditions, and as already observed for planar layers, this often leads to crack formation.¹⁸ Therefore, it is crucial to investigate the influence of cracks on the optical properties of the

active region. To do so, a preferred technique is cathodoluminescence (CL) spectroscopy.^{19,20} However, CL spectroscopy does not allow to separate changes in light extraction efficiency (LEE) and internal quantum efficiency (IQE). To overcome these limitations, time-resolved CL (TR-CL) techniques have been proposed.^{21,22}

Here, using a spatially resolved time-correlated CL (SRTC-CL) setup,^{23,24} we probe the carrier dynamics near cracks in core-shell GaN/AlGaIn microwires with a spatial resolution of 50 nm and a temporal resolution better than 40 ps (see [supplementary material](#) Sec. III for details about the timing resolution estimation). We obtain the distributions of emission peak energies, CL lifetimes, and CL intensities around such a defect. By comparing our experimental data with 6×6 k.p Schrödinger simulations, we are able to explain the observed behaviors. These results give precious information about the carrier dynamics around cracks and confirm the relevance of such a technique to elucidate the influence of defects on III-nitride nanostructures.

The studied GaN microwires with a core-shell AlGaIn heterostructure were grown on *c*-plane sapphire substrates by metalorganic vapor-phase epitaxy (MOVPE). The wires are mainly N-polar but may exhibit polarity mixing. The growth is initiated with a heavily n-doped (10^{20} cm^{-3}) GaN wire core grown under high silane flux ($\approx 200 \text{ nmol min}^{-1}$), which favors the vertical growth.²⁵ Then, an undoped GaN section is grown. The shell, which preferentially grows on the undoped GaN core, starts from an unintentionally doped GaN spacer ($\approx 150 \text{ nm}$) to bury the contamination surface layer.²⁶ Then, the active region containing five AlGaIn/AlGaIn quantum wells (QWs) is grown at 950°C under N_2 (100 mbar) with a V/III ratio close to 1000. The Al-content in the barrier has been estimated to be around $70 \pm 10\%$, while the Al content is close to $45 \pm 5\%$ in QWs (estimation based on x-ray diffraction performed on *c*-plane AlGaIn layers grown under identical conditions).²⁷ [Figure 1\(a\)](#) displays a 45°C -tilted scanning electron microscopy (SEM) image of typical as-grown wires. Due to the large lattice mismatch between the GaN core and the Al-rich AlGaIn shell, we observe the formation of cracks for most of the wires [[Fig. 1\(b\)](#)].

In a core-shell geometry, the strain is mainly enhanced along the *c*-axis (ϵ_{zz}).^{14,28} For this reason, these cracks preferentially form perpendicular to the *c*-axis, along the *a*-axis. To precisely determine the structural properties of these defects, longitudinal cross sections have been prepared by a focused Ga-ion beam using STRATA 400S

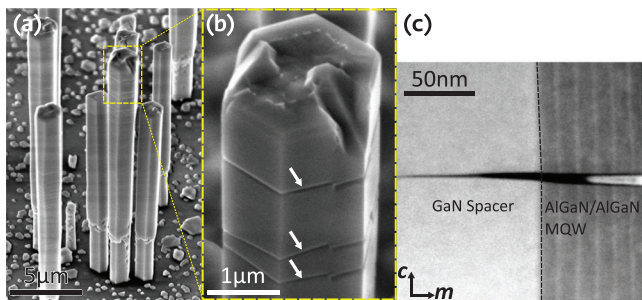


FIG. 1. (a) and (b) 45°C -tilted SEM image of GaN wires covered with Al-based MQWs grown on a *c*-sapphire substrate. (b) Enlarged view near the wire top with the presence of multiple cracks. (c) HAADF-STEM longitudinal cross section near a radial crack.

equipment and observed by scanning transmission electron microscopy (STEM) using a FEI-Tecna microscope operated at 200 kV. [Figure 1\(c\)](#) shows a cross-sectional STEM image, allowing us to deduce the QW and barrier thicknesses, respectively, equal to $4 \pm 1 \text{ nm}$ and $10 \pm 1 \text{ nm}$. We observe that the crack runs through the entire AlGaIn heterostructure and terminates in the GaN spacer. The thickness of the heterostructure does not seem to be affected by the presence of the crack. EDX measurements have also been performed, showing no significant variation in the Al-content (see [supplementary material](#) Sec. VII). This suggests that cracks appear at the end of the growth or upon cooldown.²⁹

To probe the influence of cracks on the optical properties, we performed 5K-CL measurements. First, microwires are mechanically dispersed on SiO_2/Si substrates. For each wire, CL spectra are acquired in the 3.7–4.9 eV energy range with a 2 kV acceleration voltage and a dwell time of 10 ms. Monte Carlo simulations allow us to estimate the statistical distribution of the electron penetration depth.³⁰ In this given configuration, only the first three QWs are expected to contribute to the luminescence (detailed in [supplementary material](#) Sec. V). An SEM image of a typical wire with multiple cracks is shown in [Fig. 2\(a\)](#). [Figure 2\(b\)](#) shows the corresponding CL map integrated over the wire's width in the MQW energy region. The MQW emission energy is slightly shifting to higher emission energy from bottom to the top probably due to an Al gradient along the wire or a change in the QW thickness. Even if cracks can be difficult to locate on SEM images, they can easily be seen on the CL spectra map. In fact, the presence of a crack systematically leads to an energy blue-shift of about 100 meV associated with a significant increase in CL intensity (see [supplementary material](#) Sec. IV for high resolution monochromatic CL images).

We compared our observations with two-dimensional 6×6 k.p simulations performed with the nextnano3 software.³¹ The parameters

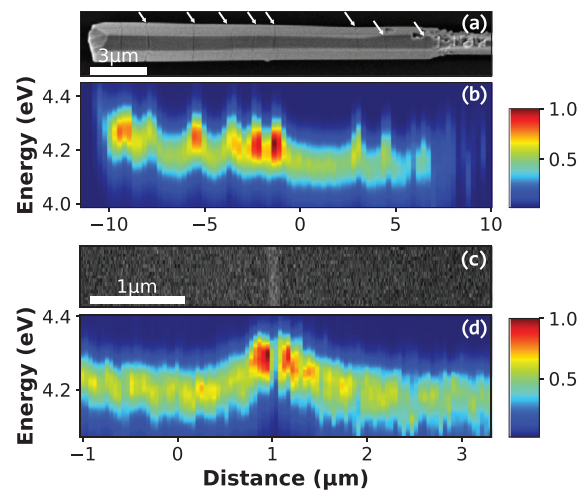


FIG. 2. (a) SEM image of a full wire and (b) the corresponding mapping of the CL spectra along the wire. (c) Close-view SEM image near a crack on a different wire and its corresponding CL spectra map (d). The measurements were done at 5 K with a 5 kV acceleration voltage for (a) and (b) and 2 kV for (c) and (d). The horizontal axis corresponds to the *c*-axis. The color bars indicate the normalized CL intensity.

used can be found in Ref. 32. The simulated system is a replica of the observed stacking in the TEM cross sections [Fig. 1(c)]. To reproduce the experimental transition energies, the Al content in the MQWs has been adjusted to 40% and 60% in the barrier. The MQW structure is assumed to be pseudomorphic on an *m*-plane GaN substrate. We first perform strain minimization to estimate the strain state of each layer. Then, we compute the band edges profiles to take into account the influence of strain on the valence and conduction bands. Finally, the Schrödinger equation is solved for both the electrons and holes in the five QWs at different positions. Figure 3(a) shows the simulated bandgap energy. 500 nm away from the crack, the energy of the bandgap tends toward the crack-free value (4.24 eV). As we come closer, thanks to the free surface, the strain is relaxed and the bandgap energy increases. We then solve the Schrödinger equation to take into account the influence of strain on confined states. It is important to note that the absolute value of the simulated energy is higher than that in our observations. This difference (≈ 170 meV) could be explained since the exciton binding energy (40–50 meV) is not considered in our simulation. In addition, our model does not take into account the impact of localization at low temperature, which can lead to a 50–60 meV red-shift of the emission energy.³³ This difference may also be attributed to the uncertainty on the Al content in the heterostructure. To estimate the influence of the exact Al composition on the energy shift close to the crack, several simulations have been performed by changing the Al content in the MQWs from 40% to 50%. As shown in supplementary material Sec. VI, the Al content in the MQWs does not drastically modify the energy shift when changing the Al content in the MQWs from 40% to 50%.

In Fig. 3(b), the experimental CL energy shift is compared to the energy shift of the transition energy obtained by simulations. The error bars of the experimental data are set to 11 meV, which corresponds to the standard deviation of CL mean energy at more than one micrometer away from the crack. As the energy of the QWs depends on their distance to the GaN spacer due to strain relaxation, only the minimum and maximum energy are indicated by crosses and the intermediate values are indicated by ribbons.

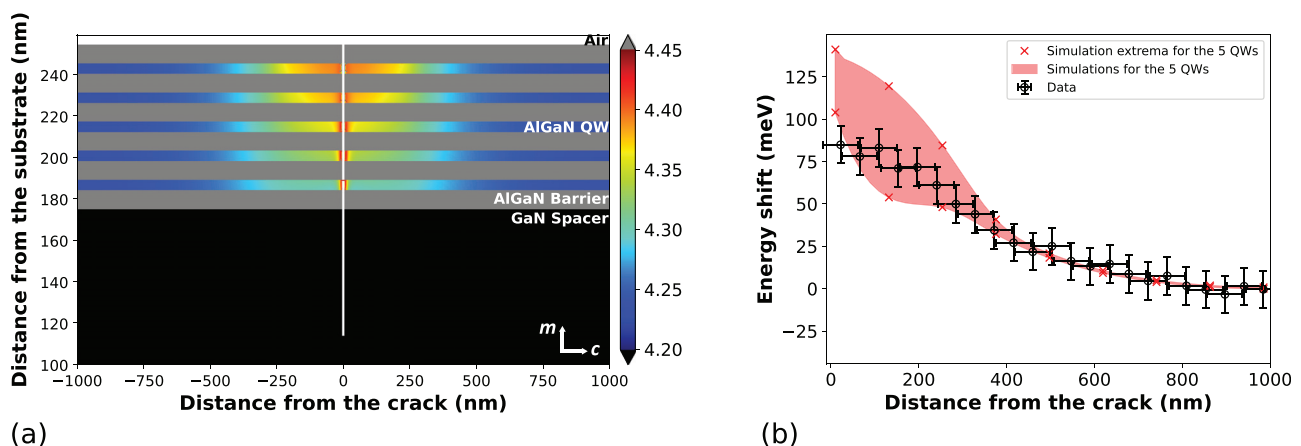


FIG. 3. (a) Mapping of the local bandgap energy in the five QWs near a crack with nextnano3 calculations. The air appears in white, the AlGaIn barriers in gray, and the GaN spacer in black. (b) Comparison between simulated and experimental energy shift as a function of the distance to the crack. The simulations correspond to the lowest energy transitions in the MQWs obtained by solving the Schrödinger equation for both holes and electrons. Both (a) and (b) were simulated with an Al content of 40% in the MQWs and 60% in the barriers.

To probe the carrier dynamics near such a crack, we carried out spatially resolved time-correlated CL (SRTC-CL)²² measurements. In this configuration, a Hanbury-Brown and Twiss interferometer is used to measure the CL photon autocorrelation function (g_2). Thanks to the specificity of the electron-matter interactions (a single incoming electron creates multiple electron-hole pairs), this technique allows us to measure the carrier lifetime.²³ Its main advantage is the ability to measure carrier lifetime at the nanometer scale without the expense of a pulsed electron gun or ultrafast beam blaster. In detail, the collected CL light is sent to two fast photodetectors (PMA Hybrid 06 from Picoquant) thanks to a 50/50 beam splitter. The two detectors are connected to a time-correlated single photon counting module (PicoHarp 300 from Picoquant): one detector acts as a clock and the other one as a detector (see supplementary material Sec. I). The delays between the clock and the detector are stored in a histogram which for short delays is proportional to the g^2 autocorrelation function (1). By fitting the exponential decay of this function, we access the effective lifetime τ_{eff} defined in (2),

$$g^2(t) = 1 + g_0 \exp(-t/\tau_{eff}), \quad (1)$$

$$1/\tau_{eff} = 1/\tau_r + 1/\tau_{nr}, \quad (2)$$

where τ_r (respectively, τ_{nr}) refers to the radiative (respectively, non-radiative) lifetime and $g_0 + 1$ is the amplitude of photon bunching at zero delay (also see supplementary material Sec. II).

In Fig. 4, the normalized CL intensity and the CL effective lifetime are shown as a function of the distance to the crack. About 400 nm away from the crack, the CL intensity starts to increase to reach 1.4 times the intensity of the crack-free region at 100 nm. Under 100 nm, the intensity quickly decreases to its minimum, which corresponds to 0.7 times the crack-free region. The lifetime is strictly decreasing with the distance, and it ranges from 475 ps at one micrometer away from crack to 285 ps near the crack.

We can consider that this lifetime reduction is driven either by the radiative or the non-radiative lifetime. The first hypothesis is very unlikely. Indeed, assuming that only the radiative lifetime is modified,

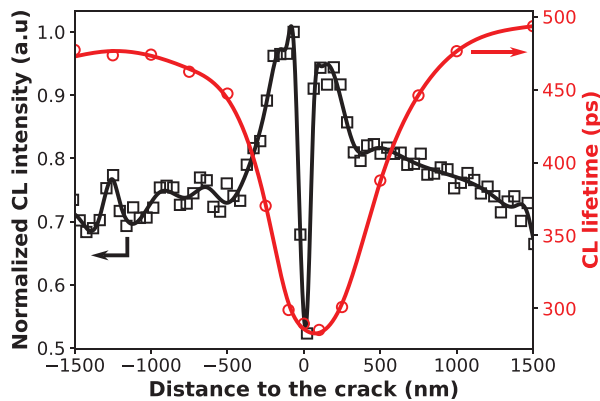


FIG. 4. Normalized CL intensity of the MQW (black squares) and CL lifetime (red circles) as a distance to the crack acquired at $T = 5$ K. The lifetime has been acquired with a SRTC-CL setup.

it is possible to extract the non-radiative lifetime $\tau_{nr} = 920 \pm 88$ ps and the radiative lifetime near the crack $\tau_{r,crack} = 410 \pm 42$ ps and far from the crack $\tau_{r,bulk} = 980 \pm 135$ ps. Such an improvement would correspond to a significant increase in oscillator strength (more than a factor of 2), which is not seen in our simulations.

Therefore, the reduction of effective lifetime near the crack is assigned to the increasing influence of non-radiative recombinations near the surface. This lifetime reduction could originate from the strong electric field at the surface due to Fermi level pinning and piezoelectric fields.³⁴ Such a field dissociates excitons and spatially separates electron-hole pairs, preventing them from radiative recombinations. This lifetime shortening could also be linked to the formation of non-radiative centers in the near-surface region associated with crack generation. In addition, the increase in CL intensity is most likely due to a local improvement of LEE. This local LEE increase has two origins. First, by locally breaking the symmetry of the structure, the crack could act as a scattering center for the emitted light, which thus offers a possible coupling to the free space. Due to the GaN core parasitic absorption ($\alpha_{\text{GaN}}(4.2 - 4.4 \text{ eV}) \approx 2 \times 10^5 \text{ cm}^{-1}$),³⁵ UV photons emitted in the wire can only propagate on few hundreds of nanometers. As a consequence, only the light generated close to the crack would benefit from a better extraction efficiency, which is consistent with our observations (see Fig. 4). Second, as evidenced by our simulations (not shown here), the change of the strain state near the crack induces a reordering of the valence bands.^{36,37} Due to their different selection rules, it should result in a change of polarization direction of the emitted light. Since LEE drastically depends on the light polarization,¹ such a crossover could locally increase the observed CL intensity. To further confirm this hypothesis, polarization-dependent CL measurements should be performed.³⁸

In conclusion, by probing the optical properties of GaN wires with Al-rich core-shell MQWs using SRTC-CL, we demonstrate the influence of cracks on the efficiency of the active region. Driven by strain relaxation, the MQW emission energy increases near the crack (≈ 100 meV). In addition, we observe an increase in CL intensity near the crack that is assigned to a local increase in the LEE. On the other hand, the carrier lifetime experiences a pronounced decrease close to the extended defect due to non-radiative recombinations that occur

near the crack surface. Our results emphasize the need for time-resolved CL to reveal the change, at the nanometer scale, in IQE without being affected by local changes of LEE.

See the [supplementary material](#) for a description of (I) the experimental setup, (II) the SRTC-CL operation principle, (III) time resolution estimation, (IV) additional CL measurements, (V) Casino simulations, (VI) the effect of the Al content on the transition emission energy, and (VII) EDX measurements.

This work is supported by the French National Research Agency in the framework of the “Investissements d’avenir” program (ANR-15-IDEX-02), by the French-Irish program ULYSSES administered by the Irish Research Council and Campus-France, and by Science Foundation Ireland through Award Nos. 18/TIDA/6066 and 12/RC/2276_P2. The authors would like to thank Fabrice Donatini for his help in the development of the SRTC-CL setup and Hanako Okuno for her help with the EDX measurements.

DATA AVAILABILITY

The data that support the findings of this study are available from the corresponding authors upon reasonable request.

REFERENCES

- M. Kneissl, *III-Nitride Ultraviolet Emitters*, Springer Series in Materials Science Vol. 227, edited by M. Kneissl and J. Rass (Springer International Publishing, Cham, 2016).
- T. Takano, T. Mino, J. Sakai, N. Noguchi, K. Tsubaki, and H. Hirayama, “Deep-ultraviolet light-emitting diodes with external quantum efficiency higher than 20% at 275 nm achieved by improving light-extraction efficiency,” *Appl. Phys. Express* **10**, 031002 (2017).
- M. Shatalov, W. Sun, A. Lunev, X. Hu, A. Dobrinsky, Y. Bilenko, J. Yang, M. Shur, R. Gaska, C. Moe, G. Garrett, and M. Wraback, “AlGaIn deep-ultraviolet light-emitting diodes with external quantum efficiency above 10%,” *Appl. Phys. Express* **5**, 082101 (2012).
- Y. Taniyasu, M. Kasu, and T. Makimoto, “An aluminium nitride light-emitting diode with a wavelength of 210 nanometres,” *Nature* **441**, 325–328 (2006).
- M. Kneissl, T.-Y. Seong, J. Han, and H. Amano, “The emergence and prospects of deep-ultraviolet light-emitting diode technologies,” *Nat. Photonics* **13**, 233–244 (2019).
- S. Zhao, A. T. Connie, M. H. T. Dastjerdi, X. H. Kong, Q. Wang, M. Djavid, S. Sadaf, X. D. Liu, I. Shih, H. Guo, and Z. Mi, “Aluminum nitride nanowire light emitting diodes: Breaking the fundamental bottleneck of deep ultraviolet light sources,” *Sci. Rep.* **5**, 8332 (2015).
- A. M. Siladie, G. Jacopin, A. Cros, N. Garro, E. Robin, D. Caliste, P. Pochet, F. Donatini, J. Pernot, and B. Daudin, “Mg and In codoped p-type AlN nanowires for pn junction realization,” *Nano Lett.* **19**, 8357–8364 (2019).
- N. H. Tran, B. H. Le, S. Zhao, and Z. Mi, “On the mechanism of highly efficient p-type conduction of Mg-doped ultra-wide-bandgap AlN nanostructures,” *Appl. Phys. Lett.* **110**, 032102 (2017).
- O. Landré, D. Camacho, C. Bougerol, Y. M. Niquet, V. Favre-Nicolin, G. Renaud, H. Renevier, and B. Daudin, “Elastic strain relaxation in GaN/AlN nanowire superlattice,” *Phys. Rev. B* **81**, 153306 (2010).
- P.-M. Coulon, G. Kusch, R. W. Martin, and P. A. Shields, “Deep UV emission from highly ordered AlGaIn/AlN core-shell nanorods,” *ACS Appl. Mater. Interfaces* **10**, 33441–33449 (2018).
- Q. Wang, H. P. T. Nguyen, K. Cui, and Z. Mi, “High efficiency ultraviolet emission from $\text{Al}_x\text{Ga}_{1-x}\text{N}$ core-shell nanowire heterostructures grown on Si (111) by molecular beam epitaxy,” *Appl. Phys. Lett.* **101**, 043115 (2012).
- M. D. Brubaker, K. L. Genter, A. Roshko, P. T. Blanchard, B. T. Spann, T. E. Harvey, and K. A. Bertness, “UV LEDs based on p-i-n core-shell AlGaIn/GaN

- nanowire heterostructures grown by N-polar selective area epitaxy," *Nanotechnology* **30**, 234001 (2019).
- ¹³P.-M. Coulon, G. Kusch, E. D. Le Boulbar, P. Chausse, C. Bryce, R. W. Martin, and P. A. Shields, "Hybrid top-down/bottom-up fabrication of regular arrays of AlN nanorods for deep-UV core-shell LEDs," *Phys. Status Solidi B* **255**, 1700445 (2018).
- ¹⁴C. Durand, C. Bougerol, J.-F. Carlin, G. Rossbach, F. Godel, J. Eymery, P.-H. Jouneau, A. Mukhtarova, R. Butté, and N. Grandjean, "M-plane GaN/InAlN multiple quantum wells in core-shell wire structure for UV emission," *ACS Photonics* **1**, 38–46 (2014).
- ¹⁵V. Grenier, S. Finot, G. Jacopin, C. Bougerol, E. Robin, N. Mollard, B. Gayral, E. Monroy, J. Eymery, and C. Durand, "UV emission from GaN wires with m-plane core-shell GaN/AlGaIn multiple quantum wells," *ACS Appl. Mater. Interfaces* **12**, 44007–44016 (2020).
- ¹⁶X. Dai, A. Messanvi, H. Zhang, C. Durand, J. Eymery, C. Bougerol, F. H. Julien, and M. Tchernycheva, "Flexible light-emitting diodes based on vertical nitride nanowires," *Nano Lett.* **15**, 6958–6964 (2015).
- ¹⁷M. Tchernycheva, A. Messanvi, A. de Luna Bugallo, G. Jacopin, P. Lavenus, L. Rigutti, H. Zhang, Y. Halioua, F. H. Julien, J. Eymery, and C. Durand, "Integrated photonic platform based on InGaIn/GaN nanowire emitters and detectors," *Nano Lett.* **14**, 3515–3520 (2014).
- ¹⁸S. Einfeldt, V. Kirchner, H. Heinke, M. Dießelberg, S. Figge, K. Vogeler, and D. Hommel, "Strain relaxation in AlGaIn under tensile plane stress," *J. Appl. Phys.* **88**, 7029–7036 (2000).
- ¹⁹S. Einfeldt, M. Dießelberg, H. Heinke, D. Hommel, D. Rudloff, J. Christen, and R. F. Davis, "Strain in cracked AlGaIn layers," *J. Appl. Phys.* **92**, 118–123 (2002).
- ²⁰D. Rudloff, T. Riemann, J. Christen, Q. K. K. Liu, A. Kaschner, A. Hoffmann, C. Thomsen, K. Vogeler, M. Dießelberg, S. Einfeldt, and D. Hommel, "Stress analysis of Al_xGa_{1-x}N films with microcracks," *Appl. Phys. Lett.* **82**, 367–369 (2003).
- ²¹W. Liu, J.-F. Carlin, N. Grandjean, B. Deveaud, and G. Jacopin, "Exciton dynamics at a single dislocation in GaN probed by picosecond time-resolved cathodoluminescence," *Appl. Phys. Lett.* **109**, 042101 (2016).
- ²²S. Meuret, L. H. G. Tizei, T. Auzelle, R. Songmuang, B. Daudin, B. Gayral, and M. Kociak, "Lifetime measurements well below the optical diffraction limit," *ACS Photonics* **3**, 1157–1163 (2016).
- ²³S. Meuret, T. Coenen, S. Y. Woo, Y. H. Ra, Z. Mi, and A. Polman, "Nanoscale relative emission efficiency mapping using cathodoluminescence g(2) imaging," *Nano Lett.* **18**, 2288–2293 (2018).
- ²⁴S. Meuret, M. Solà Garcia, T. Coenen, E. Kieft, H. Zeijlemaker, M. Lätzel, S. Christiansen, S. Y. Woo, Y. H. Ra, Z. Mi, and A. Polman, "Complementary cathodoluminescence lifetime imaging configurations in a scanning electron microscope," *Ultramicroscopy* **197**, 28–38 (2019).
- ²⁵R. Koester, J. S. Hwang, C. Durand, D. Le Si Dang, and J. Eymery, "Self-assembled growth of catalyst-free GaN wires by metal-organic vapour phase epitaxy," *Nanotechnology* **21**, 015602 (2010).
- ²⁶A. Kapoor, S. Finot, V. Grenier, E. Robin, C. Bougerol, J. Bleuse, G. Jacopin, J. Eymery, and C. Durand, "Role of underlayer for efficient core-shell InGaIn QWs grown on m-plane GaN wire sidewalls," *ACS Appl. Mater. Interfaces* **12**, 19092–19101 (2020).
- ²⁷D. V. Dinh, N. Hu, Y. Honda, H. Amano, and M. Pristovsek, "Aluminium incorporation in polar, semi- and non-polar AlGaIn layers: A comparative study of x-ray diffraction and optical properties," *Sci. Rep.* **9**, 15802 (2019).
- ²⁸K. Hestroffer, R. Mata, D. Camacho, C. Leclere, G. Tourbot, Y. M. Niquet, A. Cros, C. Bougerol, H. Renevier, and B. Daudin, "The structural properties of GaN/AlIn core-shell nanocolumn heterostructures," *Nanotechnology* **21**, 415702 (2010).
- ²⁹S. Figge, H. Kröncke, D. Hommel, and B. M. Epelbaum, "Temperature dependence of the thermal expansion of AlN," *Appl. Phys. Lett.* **94**, 101915 (2009).
- ³⁰D. Drouin, A. R. Couture, D. Joly, X. Tastet, V. Aimez, and R. Gauvin, "CASINO V2.42-A fast and easy-to-use modeling tool for scanning electron microscopy and microanalysis users," *Scanning* **29**, 92–101 (2007).
- ³¹S. Birner, T. Zibold, T. Andlauer, T. Kubis, M. Sabathil, A. Trellakis, and P. Vogl, "nextnano: General purpose 3D simulations," *IEEE Trans. Electron Devices* **54**, 2137–2142 (2007).
- ³²I. Vurgaftman and J. R. Meyer, "Band parameters for nitrogen-containing semiconductors," *J. Appl. Phys.* **94**, 3675–3696 (2003).
- ³³C. Frankerl, F. Nippert, M. P. Hoffmann, H. Wang, C. Brandl, H.-J. Lugauer, R. Zeisel, A. Hoffmann, and M. J. Davies, "Strongly localized carriers in Al-rich AlGaIn/AlIn single quantum wells grown on sapphire substrates," *J. Appl. Phys.* **127**, 095701 (2020).
- ³⁴V. M. Kaganer, J. Lähnemann, C. Pfüller, K. K. Sabelfeld, A. E. Kireeva, and O. Brandt, "Determination of the carrier diffusion length in GaN from cathodoluminescence maps around threading dislocations: Fallacies and opportunities," *Phys. Rev. Appl.* **12**, 054038 (2019).
- ³⁵T. Kawashima, H. Yoshikawa, S. Adachi, S. Fuke, and K. Ohtsuka, "Optical properties of hexagonal GaN," *J. Appl. Phys.* **82**, 3528–3535 (1997).
- ³⁶L. Rigutti, G. Jacopin, L. Largeau, E. Galopin, A. De Luna Bugallo, F. H. Julien, J.-C. Harmand, F. Glas, and M. Tchernycheva, "Correlation of optical and structural properties of GaN/AlIn core-shell nanowires," *Phys. Rev. B* **83**, 155320 (2011).
- ³⁷G. Jacopin, L. Rigutti, S. Bellei, P. Lavenus, F. H. Julien, A. V. Davydov, D. Tsvetkov, K. A. Bertness, N. A. Sanford, J. B. Schlager, and M. Tchernycheva, "Photoluminescence polarization in strained GaN/AlGaIn core/shell nanowires," *Nanotechnology* **23**, 325701 (2012).
- ³⁸M. Fouchier, N. Rochat, E. Pargon, and J. P. Landesman, "Polarized cathodoluminescence for strain measurement," *Rev. Sci. Instrum.* **90**, 043701 (2019).